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PATENT NUMBER and
ISSUE DATE

U.S. UTILITY Patent Application

| APPL NUM | FILING DATE | CLASS | SUBCLASS | GAU | EXAMINER |
|----------|-------------|-------|----------|------|----------|
| 10042060 | 01/07/2002 | 117 | | 1765 | ANDERSON |

**APPLICANTS: Kuhn Harald; Stein Rene; Voelkl Johannes;

**CONTINUING DATA VERIFIED:

THIS APPLICATION IS A CON OF PCT/DE00/02174 07/04/2000

10/29/05

** FOREIGN APPLICATIONS VERIFIED:

GERMANY 199 31 333.4 07/07/1999

10/29/05

| | | |
|---|---|----------------------------------|
| PG-PUB | DO NOT PUBLISH <input type="checkbox"/> | RESCIND <input type="checkbox"/> |
| Foreign priority claimed | <input checked="" type="checkbox"/> yes <input type="checkbox"/> no | ATTORNEY DOCKET NO |
| 35 USC 119 conditions met | <input checked="" type="checkbox"/> yes <input type="checkbox"/> no | GR99P3456 |
| Verified and Acknowledged Examiners's initials <i>MM</i> | | |
| TITLE : Method for the sublimation growth of an SiC single crystal, involving heating under growth pressure | | |

U.S. DEPT. OF COMM./PAT. & TM.-PTO-436L (Rev. 12-94)

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| NOTICE OF ALLOWANCE MAILED | | CLAIMS ALLOWED | | |
|---|--|----------------------|-------------|----------------------|
| | | Total Claims | | Print Claim for O.G. |
| Assistant Examiner | | DRAWING | | |
| Amount Due | | Sheets Drwg. | Figs. Drwg. | Print Fig. |
| Date Paid | | Application Examiner | | |
| <input type="checkbox"/> TERMINAL DISCLAIMER | | PREPARED FOR ISSUE | | |
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